Monday, March 5, 2012

7:30 am-5:00 pm **Registration**

7:30 am-10:30 am

Equipment Exhibit Setup

7:30 am-10:30 am Student Poster Setup

8:00 am-9:05 am

Welcome and Introduction

Program Chair: Kerry Siebein (National Institute of Standards)

8:05 am-9:00 am

Keynote Address: History of Vacuum Technology-(My Perspective)

Kurt J. Lesker III, Kurt J. Lesker Company

Surface Science

Chair: Wei David Wei, University of Florida

9:00 am-9:25 am

Photoinduced Magnetization Effects in Nanometer Scale Heterostructures of Prussian Blue Analogs

(Invited) Daniel R. Talham, Dept. of Chemistry, University of Florida

9:25 am-9:50 am

Structure-Specific Plasmonics

(Invited) Kenneth L. Knappenberger, Jr., Florida State University

09:50 am-10:15 am

Fundamental Growth Mechanisms of Graphene on Nickel Surfaces

(Invited) Matthias Batzill, Dept. of Physics, University of South Florida

10:15 am-10:45 am

Coffee Break (sponsored by <u>JEOL USA, Inc.</u>)

Nanoelectronics

Chair: Saiful Khondaker, University of Central Florida

10:45 am-11:10 am

Large Area Electronics with Graphene Oxide

(Invited) Manish Chowalla, Dept. of Materials Science and Eng., Rutgers University

11:10 am-11:35 am

Carbon Nanotube Film-Silicon Junctions: Electronic Properties and Device Characterization

(Invited) Ant Ural, Dept. of Electrical and Computer Eng., University of Florida

11:35 am-12:00 pm

Trends in Nanoelectronics in Wider Scope

(Invited) Robert Redhammer, Marian Vesely, Andrej Vincze, Slovak University of Technology, Slovakia

12:00 pm-01:20 pm

Lunch Break

Microscopy in the Biological and Physical Sciences/FIB

Chair: Lucille Giannuzzi, Giannuzzi & Associates

1:20 pm-3:00 pm

The SHIRLEY Background in Overlapping XPS Peaks

(Invited) Mariela Bravo-Sanchez, <u>Alberto Herrera-Gomez</u>, CINVESTAV-Unidad Querétaro, México

1:45 pm-2:10 pm

Laser Modification of Surfaces in a FIB/SEM

(Invited) <u>David J. Hwang</u>^{1,2,*}, Costas P. Grigoropoulos^{3,4}, Andrew M. Minor^{5,6}, ¹State University of New York, Stony Brook, ²Laser Solar PV Laboratory, Advanced Energy Research and Technology Center, Stony Brook, ³Dept. of Mech. Eng., University of California, ⁴Advanced Energy Technologies Dept, EETD, Lawrence Berkeley National Laboratory, ⁵Dept. of Material Science and Eng., University of California, ⁶National Center for Electron Microscopy, Lawrence Berkeley National Laboratory

2:10 pm-2:35 pm

Enhanced Properties of Multiferroic Nanocomposite Materials: An Electron Microscopy Study

(Invited) Jennifer S. Andrew, Dept. of Materials Science and Eng., University of Florida

2:35 pm-3:00 pm

Cs-Corrected STEM for Imaging and Spectroscopy of Complex Oxides and Catalysts

(Invited) <u>Dong Su</u>, Center for Functional Nanomaterials, Brookhaven National Lab

3:00 pm-3:30 pm

Coffee Break (sponsored by Turbo Vacuum)

Young Leader's Session

<u>Chairs</u>: Edward Wrzesniewski, University of Florida Daniel Yates, University of Central Florida

3:30 pm-3:45 pm

High-Efficiency, Solution-Processed Hybrid Organic-Inorganic Photovoltaic Cells Renjia Zhou, Ying Zheng, Lei Qian, Paul H. Holloway, and Jiangeng Xue, Department of Materials Science & Engineering, University of Florida, Gainesville, FL 32611

3:45 pm-4:00 pm

Absorption from Plasmonic Antenna Arrays

<u>Kathryn E. O'Brien</u>¹, Po-Yuan Wang¹, Paul H. Holloway¹, Mark R. Davidson¹, ¹Department of Materials Science & Engineering, University of Florida, Gainesville, FL

4:00 pm-4:15 pm

Epitaxial Growth of MgO and Cubic ZnMgO by Plasma-Enhanced Molecular Beam Epitaxy

R. Casey Boutwell, M. Wei, Winston V. Schoenfeld, CREOL & FPCE - The College of Optics & Photonics, The University of Central Florida

4:15 pm-4:30 pm

Graphene Enabled Vertical Field Effect Transistors

M. Lemaitre, B. P. Gila, B. R. Appleton, Department of Materials Science & Engineering, University of Florida, Gainesville, FL 32611

4:30 pm-4:45 pm

Synchrotron X-ray Scattering Investigation of Thin Film Interface Kinetics

Andrew P. Warren¹, Michael F. Toney², Katayun Barmak³, Ivan I. Kravchenko⁴, Kevin R. Coffey¹, ¹Advanced Materials Processing and Analysis Center, University of Central Florida, ²Stanford Synchrotron Radiation Lightsource, SLAC National Accelerator Laboratory, ³Department of Materials Science and Engineering, Carnegie Mellon University, ⁴Center for Nanophase Materials Sciences, Oak Ridge National Laboratory

5:00 pm-7:00 pm

Poster Session (sponsored by <u>FESC</u>, <u>JEOL USA</u>, <u>Inc</u>. and <u>MEWASA North America</u>, <u>Inc.</u>) <u>Chair</u>: Ying Zheng, University of Florida

Reception (sponsored by <u>Physical Electronics, Inc.</u>)

Tuesday, March 6, 2012

8:00 am-12:00 pm

Registration

8:00 am-9:00 am

Poster Session (sponsored by <u>FESC</u>, <u>JEOL USA</u>, <u>Inc</u>. and <u>MEWASA North America</u>, <u>Inc.</u>) <u>Chair</u>: Ying Zheng, University of Florida

Renewable Energy

<u>Chairs</u>: Neelkanth Dhere, Florida Solar Energy Center, University of Central Florida Tim Anderson, Florida Program for Alternative Energies, University of Florida

9:00 am-9:25 am

Specialty Glasses for Photovoltaics

(Invited) James E Webb, Corning Incorporated

9:25 am-9:50 am

CIGS and CZTS Thin Film Solar Cells

(Invited) <u>Eray S. Aydil</u>, Dept. of Chemical Eng. and Materials Science, University of Minnesota

9:50 am-10:15 am

Depth Profiling of Organic Electronic Materials

(Invited) John S. Hammond, Physical Electronics, Inc.

10:15 am-10:35 am

Coffee Break (sponsored by Oerlikon Leybold Vacuum)

Thin Films

<u>Chairs</u>: Winston Schoenfeld, University of Central Florida & Mei Zhang, Florida State University

10:35 am-11:00 am

Atmospheric Plasma for the Deposition of Thin Coatings: Some Examples (Invited) François Reniers, University Libre de Bruxelles, Belgium

11:00 am-11:25 am

Electronic Functionality in Thin Oxide Films: 2-D Electron Liquid at LaAlO₃/SrTiO₃ Interfaces

(Invited) <u>Maitri P. Warusawithana</u>, National High Magnetic Field Laboratory, Florida State University

11:25 am-11:50 am

Growth of II-Oxide Wide-Bandgap Semiconductors for UV Applications

(Invited) M. Wei *, R. C. Boutwell, and W. V. Schoenfeld, University of Central Florida

11:50 am-12:15 pm

An Electrically Stimulated Plasmonic Light Source

(Invited) Mark Davidson^{1,2}, Jonathan Gorrell¹, Michael Maines¹, Lev Gasprov^{1,3}, Jean Tokarz¹, Andres Trucco¹, Sean Jones^{1,2}, ¹Advanced Plasmonics, Inc., ²University of Florida, ³University of North Florida

12:15 pm-1:30 pm Lunch Break

Characterization of Nano/Bio Materials

Chair: Andre Gesquiere, University of Central Florida

1:30 pm-1:55 pm

Application of Extremely Non-Equilibrium Oxygen Plasma: From Nanoscience to Bio-Medicine

(Invited) Miran Mozetic, Dept. of Surface Eng., Jozef Stefan Institute, Ljubljana, Slovenia

1:55 pm-2:20 pm

Activable Luminescent Quantum Dot Based Nanoprobes for Potential Biomedical Applications

(Invited) <u>Swadeshmukul Santra</u> a.b.c.*, Subhash Banerjee^a, Rajendra Narayan Mitra^a, Andrew Teblum^{a,c}, Mona Doshi^{a,b}, Jessica C. Tyus^{a,b}, Xiaolei Zhang^c, Niclas Bengtsson^e, Andre Gesquiere^{a,b,d}, Patrick T. Gunning^f and Glenn A. Walter^e, aNanoScience Technology Center, University of Central Florida, bDept. of Chemistry, University of Central Florida, University of Central Florida, Physiology and Functional Genomics, University of Florida, Dept. of Chemistry, University of Toronto at Mississauga, Canada

2:20 pm-2:45 pm

Stimuli-Response Organic Tubes Based on the Self-Assembly of Biological Surfactants

(Invited) <u>Jiyu Fang</u>, Advanced Materials Processing and Analysis Center, University of Central Florida

2:45 pm-3:15 pm

Coffee Break (sponsored by RBD Instruments, Inc.)

Advances in Instrumentation

Chair: Mark Davidson, University of Florida

3:15 pm-3:40 pm

Enhanced XPS Depth Profiling and Surface Sputter-Cleaning of Organic and Inorganic Materials with Argon Cluster Ion Beams

(Invited) Richard G. White¹, Tim S. Nunney¹, Paul Mack¹, Andrew E. Wright¹, and <u>Brian R. Strohmeier²</u>, ¹Thermo Fisher Scientific, UK., ²Thermo Fisher Scientific, USA.

3:40 pm-4:05 pm

The Development and Application of Polyatomic Ion Species for Sputtering in X-Ray Photoelectron Spectroscopy (XPS)

(Invited) <u>David Surman</u>¹, Simon Hutton², Adam Roberts², William Boxford², Chris Blomfield², Simon Page², ¹Kratos Analytical Inc., USA, ²Kratos Analytical Ltd., UK

4:05 pm-5:00 pm Poster Award Ceremony